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INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

(Chapter II of the Patent Cooperation Treaty) (PCT Article 36 and Rule 70)

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Applicant's or agent's file reference 10012333WO01	FOR FURTHER AC	TION	See Form PCT/IPEA/416	i				
International application No.	International filing date (d		Priority date (day/month	v/year)				
PCT/JP2004/019486	20.12.	.2004	22.12.	200	3			
International Patent Classification (IPC) or national classification and IPC Int.Cl. H05K3/10(2006.01), B05C5/00(2006.01), B05C11/10(2006.01), B05D1/26(2006.01), B05D5/12(2006.01), H01L21/288(2006.01)								
Applicant CANON KABUSHIKI KAISHA								
1. This report is the international preliminary examination report, established by this International Preliminary Examining Authority under Article 35 and transmitted to the applicant according to Article 36.								
2. This REPORT consists of a total of	of3 sheets,	ncluding this cover s	heet.					
3. This report is also accompanied by	y ANNEXES, comprisin	g:						
a. 🗷 a total of 5	sheets, as follows:							
sheets of the description, claims and/or drawings which have been amended and are the basis of this report and/or sheets containing rectifications authorized by this Authority (see Rule 70.16 and Section 607 of the Administrative Instructions). sheets which supersede earlier sheets, but which this Authority considers contain an amendment that goes beyond the disclosure in the international application as filed, as indicated in item 4 of Box No. I and the								
Supplemental Bo								
b. a total of (indicate type and number of electronic carrier(s)) containing a sequence listing and/or tables related thereto, in electronic form only, as indicated in the Supplemental								
Box Relating to Sequence	e Listing (see Section 80	2 of the Administrative	e Instructions).					
4. This report contains indications re	lating to the following it	ems:						
Box No. I Basis of the	report							
Box No. II Priority								
Box No. III Non-establis	shment of opinion with re	egard to novelty, inven	tive step and industrial ap	plicabi	lity			
Box No. IV Lack of unit								
	Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement							
☐ Box No. VI Certain docu	ments cited							
Box No. VII Certain defe	cts in the international ap	plication						
Box No. VIII Certain obse	rvations on the internation	onal application						
Date of submission of the demand	Date of completion of this report							
13.10.2005		15.03.2006						
Name and mailing address of the IPEA/JP	Authorized officer		35	9341				
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INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

International application No. PCT/JP2004/019486

Box No.	. I	Basis of the report				
1. W	the in a trai	publication of the international application (Rule 1	12.4(a))	, which is the language of a		
fur	rnished	ard to the elements of the international application of the receiving Office in response to an invitation not annexed to this report):				
	the ir	international application as originally filed/furnish	hed			
区	the d	description:				
		es <u>1-41</u>		as originally filed/furnished		
	pages	es* rec				
	pages		eceived by this Authority on			
区		claims:				
	Nos.	,,		as originally filed/furnished		
	Nos.*			ny statement) under Article 19		
	Nos.* Nos.*		eceived by this Authority on 13.1			
7.4			eceived by this Authority on			
V ; she		drawings: gs 1–21		** ** ** *** *** *** *** *** *** *** *		
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5110.	ets/115°	.*	ceived by this Authority on			
	a sequ	quence listing and/or any related table(s) - see Sup	pplemental Box Relating to Sequen	ce Listing.		
3. 🔽	The a	amendments have resulted in the cancellation of:				
		the description, pages				
	V	the claims, Nos. 2, 4, 7, 13-15, 17-3	·19			
						
		the common listing ()				
		any table(s) related to sequence listing (specify				
4.	made, (Rule	This report has been established as if (some of) the amendments annexed to this report and listed below had not been made, since they have been considered to go beyond the disclosure as filed, as indicated in the Supplemental Box (Rule 70.2(c)).				
		the description, pages		 -		
		11 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1				
		the sequence listing (specify):				
		any table(s) related to sequence listing (specify)				
* If item	ı 4 appl	olies, some or all of those sheets may be marked "supe	perseded."			

INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

International application No. PCT/JP2004/019486

			35(2) with regard to novelty, inventive step or industrial ang such statement	pplicability;
1.	Statement			
	Novelty (N)	Claims Claims	1,3,5-6,8-12,16	YES NO
	Inventive step (IS)	Claims Claims	1,3,5-6,8-12,16	YES NO
	Industrial applicability ((A) Claims Claims	1,3,5-6,8-12,16	YES NO

- 2. Citations and explanations(Rule 70.7)
- D1:JP 11-274671 A(SEIKO EPSON CORPORATION) 1999.10.08(Family:None)
- D2:WO 2003/105547 A1(FUJI PHOTOFILM CO.,LTD.) 2003.12.18 & US 2003/228543 A1

Claims 1,3,5-6,8-12,16 do not involve inventive steps over D1 or D2. D1 or D2 discloses a wiring method of forming the first pattern and the second pattern on a substrate by supplying the first liquid and the second liquid to said each of the patterns independently. And it is a normal option for a person skilled in the art to decide the forming order of some patterns by considering the information of a wiring pattern.

CLAIMS

1. (Amended) A wiring forming method of supplying a first liquid and a second liquid in such a manner that said first liquid and said second liquid contact with each other on a substrate to thereby form a wiring pattern including the first pattern and the second pattern on the substrate, the method comprising:

a first pattern forming step of supplying the first liquid to thereby form the first pattern on the substrate; and

a second pattern forming step of supplying the second liquid to thereby form the second pattern on the substrate,

wherein a forming order of said first pattern and said second pattern for constituting said wiring pattern in a same layer is changed in accordance with information of said wiring pattern.

2. (Cancelled)

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3. (Amended) The wiring forming method according to claim 1, wherein curing process is performed each time said first pattern or said second pattern is formed to the substrate.

4. (Cancelled)

- 5. The wiring forming method according to claim 1, wherein the first pattern forming step comprises the steps of: forming the first patterns on a plurality of positions of the substrate, and thereafter the second pattern forming step comprises the steps of: forming the second pattern between the first patterns formed in the plurality of positions on the substrate in such a manner as to bring the second pattern into contact with the first pattern.
- 6. The wiring forming method according to claim 1, further comprising the steps of: discharging the first and second liquids by an ink jet system to thereby supply the liquids onto the substrate.

7. (Cancelled)

8. The wiring forming method according to claim 1, wherein the first pattern is an insulated pattern

having an insulating property, and the second pattern is a conductive pattern having conductivity.

- The wiring forming method according to claim
 1, wherein the first and second patterns are insulating insulated patterns having different properties.
- The wiring forming method according to claim
 wherein the first pattern is an insulated pattern
 having an insulating property, and the second pattern
 a semiconductor pattern of a semiconductor.
- 11. A wiring board comprising: a wiring formed by the wiring forming method according to claim 1; and the substrate.
- 12. (Amended) A wiring forming apparatus for supplying a first liquid forming a first pattern and a second liquid forming a second pattern in such a manner that the first liquid and the second liquid contact with each other on a substrate to thereby form a wiring pattern including said first pattern and said second wiring pattern on the substrate, the apparatus comprising:
- a first liquid container which stores the first liquid;
 - a second liquid container which stores the second

liquid;

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first pattern forming means for supplying the first liquid on the substrate from the first liquid container to thereby form the first pattern;

second pattern forming means for supplying the second liquid on the substrate from the second liquid container to thereby form the second pattern; and

means for changing a forming order of said first pattern formed by using said first pattern forming means and said second pattern formed by using said second forming means in accordance with information of said wiring pattern upon forming said wiring pattern in a same layer.

- 15 13. (Cancelled)
 - 14. (Cancelled)
 - 15. (Cancelled)

16. The wiring forming apparatus according to claim 12, wherein a size of the corresponding first pattern is changeable in accordance with that of the second pattern to be formed.

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- 17. (Cancelled)
- 18. (Cancelled)
- 10 19. (Cancelled)